

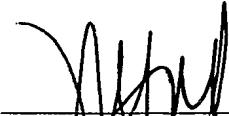


PATENT
30205/37777

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Jae Chang Jung et al.)
Serial No.: 10/054,095)
Filed: January 22, 2002)
For: Chemical Amplification)
Photoresist Monomers, Polymers)
Therefrom and Photoresist)
Compositions Containing the Same)
Group Art Unit: 1752)
Examiner: Rosemary E. Ashton)

I hereby certify that this paper and the
documents referred to as enclosed
therewith are being deposited with the
United States Postal Service as first class
mail, postage prepaid, on November 21,
2003, in an envelope addressed to
Commissioner for Patents, P.O. Box
1450, Alexandria, Virginia 22313-1450



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AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

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Dear Sir:

In response to the office action mailed on August 21, 2003, please amend the
above-identified patent application as follows: